





# **CALL FOR LOGO DESIGNS**

The annual **TU-HKU-FJMU International Symposium** is jointly organized by Tohoku University, The University of Hong Kong, and Fujian Medical University. This symposium will bring together clinicians and academics from three leading Universities in the Asia-Pacific region. Together, they will share their research findings and explore the most cutting-edge issues within the field of Oral Health Sciences.

## Call for Logo Designs

Students and staff from the three Universities are now invited to submit a Logo Design highlighting the characteristics of dental science and education, furthermore, reflecting the collaboration and friendship between the three Dental Schools. The winning design will be used by the Organizing Committee as part of their official Symposium Logo.

#### Format and Requirements

- (i) Please include a summary of not more than 200 words to describe the logo designed.
- (ii) Images should be submitted in a high-resolution JPEG file format.
- (iii) Participants can submit their work via email to <a href="mailto:lyt\_oia\_ssfmu@yeah.net">lyt\_oia\_ssfmu@yeah.net</a> with the email subject as "Participants Name & FJMU/TU/HKU"
- (iii) The closing date for submission is Wednesday 30<sup>th</sup> March 2022.
- (iv) All submissions must be of the participant's own original works.
- (v) Each participant may submit more than one design.

## **Competition Results and Awards**

The final results will be announced on the Symposium's Official Website.

The winner of the Best Logo Design will receive full sponsorship from Fujian Medical University for their attendance to the Symposium, to cover for the cost of accommodation and travel.

All finalists and eventual winner will receive an Awards Certificate in recognition for their participation in this competition.

### **Terms and Conditions**

- (i) All submitted logo designs can be used at the sole discretion of the TU-HKU-FJMU International Symposium Organizing Committee.
- (ii) The copyright of the submitted entries are protected under the Copyright Law of the People's Republic of China, Hong Kong SAR, and Japan. All entries submitted will be without infringement on the Intellectual Property Rights of any party. The organizer shall not be responsible for any liability arising from violation of Copyright Laws.
- (iii) The organizing committee reserves the final right of interpretation of this event.